



03500.016650.1

Fee purpose only ^{DFW}
PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
: Examiner: H. Philogene
SHUJI AOKI ET AL.)
: Group Art Unit: 2828
Application No.: 10/648,490)
: Filed: August 27, 2003)
: For: METHOD AND APPARATUS FOR)
ADJUSTING CHARACTERISTICS :
OF MULTI ELECTRON SOURCE) December 10, 2004

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

SUPPLEMENT TO SECOND INFORMATION DISCLOSURE STATEMENT

Sir:

A Second Information Disclosure Statement was filed in the Patent and Trademark Office on September 1, 2004. It is respectfully submitted that each item of information in the Second Information Disclosure Statement was first cited in any communication from a foreign Patent Office in a counterpart foreign application not more than three months prior to the filing date of the Information Disclosure Statement.

In view of the foregoing, the Examiner is respectfully requested to consider the art cited in the Second Information Disclosure Statement.

In any event, if a fee is required to have the Second Information Disclosure Statement considered, please charge the fee to the Deposit Account No. 06-1205.

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Applicants' undersigned attorney may be reached in our New York office by telephone at (212) 218-2100. All correspondence should continue to be directed to our below listed address.

Respectfully submitted,



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